

Filed: July 29, 2002

Our Case Docket No.: TPG 306

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

ROBERT G. WENDT, SCOTT WIEDEMAN,
JEFFREY S. BRITT, and DOUGLAS G. MASON

Serial No. : 09/613,951 Group Art Unit: 3742
Filed : July 11, 2000 Examiner Sang Yeop Paik
For : NOZZLE-BASED, VAPOR-PHASE, PLUME DELIVERY
STRUCTURE FOR USE IN PRODUCTION OF THIN-FILM
DEPOSITION LAYER

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TECHNOLOGY CENTER R3700

Commissioner for Patents
Washington, D.C. 20231

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Transmitted herewith is an AMENDMENT for filing in the above-identified application:

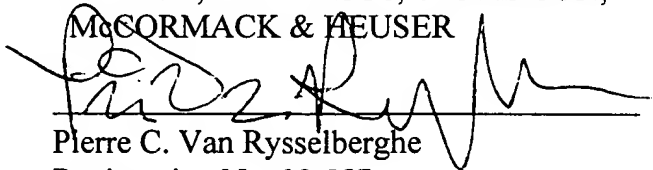
The fee has been calculated as shown below
Claims as Amended
SMALL ENTITY

(1)	(2)	(3)	(4)	(5)	(6)	(7)
	Claims remaining after amendment		Highest number previously paid for	Present extra	Rate	Additional fee
Total Claims	35	Minus	29	6	\$ 9.00	= \$ 54.00
Independent Claims	4	Minus	3	1	\$ 42.00	= \$ 42.00
This additional fee for this amendment						\$ 96.00

- ☒ Applicant hereby requests a retroactive extension of time up to and including the date of this Amendment, and the fee for this extension is submitted herewith. A duplicate copy of this sheet is enclosed.
- ☒ A check in the amount of \$556.00 is enclosed.
- ☒ Please charge any additional fees or credit overpayment to Deposit Account No. 11-1540. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

KOLISCH, HARTWELL, DICKINSON,
McCORMACK & HEUSER


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PVR:art
Enclosures



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Box AMENDMENT FEE
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Washington, D.C. 20231

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Sir:

AMENDMENT

In response to the first Office action dated January 28, 2002, please amend the
above-identified application as follows:

In the Claims:

Please amend claims 1-29 as follows:

1. (Amended) A vapor deposition effusion system, comprising:
a device configured to translate a strip material through a deposition zone and
along a processing path, each of the strip material and the deposition zone having a width
oriented perpendicular to the processing path;

a substantially closed vessel adapted to contain a heated quantity of source
material, the vessel including an array of vapor delivery nozzles distributed uniformly
across the vessel in a direction corresponding to the width of the deposition zone and